AMENDMENT TO THE CLAIMS

1. (Previously Presented) A method comprising:

selecting a dicing tape with an adhesive layer that has a thickness greater than a height of one or more bump electrodes formed on a first side of a wafer;

applying the dicing tape to the first side of the wafer such that the adhesive layer conforms to the one or more bump electrodes; and

dicing the wafer from a second side of the wafer opposite the first side, the dicing extending into the adhesive layer a distance less than a thickness of the adhesive layer.

- 2. (Previously Presented) The method of claim 1 wherein the wafer is a double bumped wafer with bump electrodes formed on the second side.
- 3. (Original) The method of claim 2 wherein the dicing tape is applied using a mounting pressure roller wherein the adhesive layer helps to distribute a pressure applied by the mounting pressure roller.
- 4. (Previously Presented) The method of claim 3 further comprising: after dicing, reducing an adhesive strength of the adhesive layer by exposing the adhesive layer to radiation.
- 5. (Original) The method of claim 4 wherein the bump electrodes have a height of approximately 60 microns and the adhesive layer has a thickness of approximately 130 microns.
- 6. (Previously Presented) The method of claim 5, wherein dicing comprises:

 dicing the wafer using a dual-blade dicing process wherein a first blade dices through less
 than an entire thickness of the wafer followed by a second blade that dices through the wafer.
- 7. (Canceled)

- 8. (Currently Amended) The method of elaim 7claim 4 wherein the adhesive strength is reduced from a pre-radiation adhesive strength of approximately 200 grams/25 mm² to a post-radiation adhesive strength of approximately 2 grams/25 mm².
- 9-13 (Canceled)
- 14. (Previously Presented) A method comprising:

 determining a height of one or more bump electrodes on a first side of a wafer surface;

 selecting a dicing tape based upon the determined height of the one or more bump

 electrodes, a first side of the dicing tape comprising an adhesive layer thicker than the

 determined height of the one or more bump electrodes;

applying the first side of the dicing tape to the first side of the wafer such that the adhesive layer conforms to the one or more bump electrodes; and

dicing the wafer from a second side of the wafer opposite the first side, the dicing extending into the adhesive layer a distance less than a thickness of the adhesive layer.

- 15. (Original) The method of claim 14 wherein the wafer is a double bumped wafer.
- 16-17. (Canceled)
- 18. (Previously Presented) The method of claim 14 wherein the dicing tape is applied using a mounting pressure roller wherein the adhesive layer helps to distribute a pressure applied by the mounting pressure roller.
- 19. (Original) The method of claim 14 wherein the dicing tape is a radiation sensitive tape having a pre-radiation adhesive strength of approximately 200 grams/25 mm², and a post-radiation adhesive strength of approximately 2 grams/25 mm².
- 20. (Original) The method of claim 14 wherein the bump electrodes have a height of approximately 60 microns and the adhesive layer has a thickness of approximately 130 microns.

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- 21. (Previously Presented) The method of claim 20 further comprising: dicing the wafer using a dual-blade dicing process.
- 22. (Previously Presented) The method of claim 21 further comprising: wherein reducing an adhesive strength comprises irradiating a second side of the dicing tape.
- 23-27 (Canceled)